

L Number	Hits	Search Text	DB	Time stamp
17	7586	implant\$5 with through with (oxide silicon adj dioxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/16 11:51
18	301	(implant\$5 with through with (oxide silicon adj dioxide)) and anneal\$3 with damage\$1 with implant\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/16 11:52
19	231	((implant\$5 with through with (oxide silicon adj dioxide)) and anneal\$3 with damage\$1 with implant\$4) and remov\$3 with (oxide silicon adj dioxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/16 11:52
20	69	((((implant\$5 with through with (oxide silicon adj dioxide)) and anneal\$3 with damage\$1 with implant\$4) and remov\$3 with (oxide silicon adj dioxide)) and (deposit\$3 with aluminum)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/16 11:57
21	162	((((implant\$5 with through with (oxide silicon adj dioxide)) and anneal\$3 with damage\$1 with implant\$4) and remov\$3 with (oxide silicon adj dioxide)) not (((implant\$5 with through with (oxide silicon adj dioxide)) and anneal\$3 with damage\$1 with implant\$4) and remov\$3 with (oxide silicon adj dioxide)) and (deposit\$3 with aluminum))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/16 11:58